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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/643,929	08/20/2003	Masayuki Endo	60188-634	5375
Jack Q. Lever, Jr. McDERMOTT, WILL & EMERY 600 Thirteenth Street, N.W. Washington, DC 20005-3096			EXAMINER	
			HOANG, QUOC DINH	
			ART UNIT	PAPER NUMBER
			2818	=
			DATE MAILED: 03/10/200	5

Please find below and/or attached an Office communication concerning this application or proceeding.

		Application No.	Applicant(s)				
		10/643,929	ENDO ET AL.				
Office Action Summary		Examiner	Art Unit				
		Quoc D. Hoang	2818				
	The MAILING DATE of this communication ap	pears on the cover she	et with the correspondence add	ress			
Period for Reply							
THE   - External after - If the - If NO - Failu Any (	ORTENED STATUTORY PERIOD FOR REPL MAILING DATE OF THIS COMMUNICATION. Insions of time may be available under the provisions of 37 CFR 1. SIX (6) MONTHS from the mailing date of this communication. In period for reply specified above is less than thirty (30) days, a replayer of the propertied above, the maximum statutory period into the reply within the set or extended period for reply will, by statute the propertied by the Office later than three months after the mailing and patent term adjustment. See 37 CFR 1.704(b).	136(a). In no event, however, i ly within the statutory minimum will apply and will expire SIX (i e, cause the application to become	nay a reply be timely filed of thirty (30) days will be considered timely. MONTHS from the mailing date of this continued the co	nmunication.			
Status							
1)⊠	Responsive to communication(s) filed on 20 A	August 2003.					
2a) <u></u>	This action is FINAL. 2b)⊠ This action is non-final.						
3)	Since this application is in condition for allowance except for formal matters, prosecution as to the ments is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.						
Disposition of Claims							
4) Claim(s) 1-19 is/are pending in the application. 4a) Of the above claim(s) is/are withdrawn from consideration.  5) Claim(s) is/are allowed.  6) Claim(s) 1-11,13-15 and 17-19 is/are rejected.  7) Claim(s) 12 and 16 is/are objected to.  8) Claim(s) are subject to restriction and/or election requirement.							
Applicati	ion Papers						
9)	The specification is objected to by the Examin	er.					
10) ☐ The drawing(s) filed on is/are: a) ☐ accepted or b) ☐ objected to by the Examiner.							
	Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).						
Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).  11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.							
Priority (	under 35 U.S.C. § 119		•				
<ul> <li>12)  Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).</li> <li>a)  All b)  Some * c) None of:</li> <li>1.  Certified copies of the priority documents have been received.</li> <li>2.  Certified copies of the priority documents have been received in Application No</li> <li>3.  Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).</li> <li>* See the attached detailed Office action for a list of the certified copies not received.</li> </ul>							
Attachmen	t(s)						
1) Notice of References Cited (PTO-892)  4) Interview Summary (PTO-413)							
3) 🛛 Infor	ee of Draftsperson's Patent Drawing Review (PTO-948) mation Disclosure Statement(s) (PTO-1449 or PTO/SB/08 er No(s)/Mail Date <u>8-03</u> .	) 5) 🔲 Noti	er No(s)/Mail Date ce of Informal Patent Application (PTO- er:	152)			

### **DETAILED ACTION**

## Claim Rejections - 35 USC § 103

- 1. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
  - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 2. Claim 1-11, 13-15, and 17-19 are rejected under 35 U.S.C. 103(a) as being unpatentable over Applicants' Admitted Prior Art in view of Hayase et al (U.S. Pat No. 5,580,702) ("Hayase").

Regarding claims 1-3, 5-10, 13, 14, 17 and 18, Applicants' Admitted Prior Art teaches a pattern formation method comprising the steps of: forming a resist film 2 made from a chemically amplified resist material; forming, on said resist film, a solution including water 3A or perfluoropolymer 3B; performing pattern exposure by selectively irradiating said resist film 2; and forming a resist pattern by developing said resist film 2 after the pattern exposure (see page 1 line 4 through 4, line 5 and Figs 8-9).

Applicants' Admitted Prior Art does not teach the solution including an acid or a water-soluble film including an acid on the resist film.

However, Hayase teaches a solution of an acidic water-soluble polymer, or a polymer layer, formed on the resist film, then the resist film is patterned-exposed by an KrF laser. (see col. 18 lines 15-32, and Example 25, and Fig. 1). At the time of the invention was made, it would have been obvious to a person of ordinary skill in the art to combine the solution of an acidic water-soluble polymer, or a polymer layer teaching of Hayase with Applicants' Admitted

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Prior Art's solution (including water or perfluoropolymer), because it would have improved the shape of resist pattern as taught by Hayase, column 15, lines 1-5, and Figs. 1-2.

Regarding claims 4 and 11, Hayase teaches wherein said acid generator is an onium salt (col. 11, lines 15-40, sulfo group).

Regarding claims 8 and 15, Hayase teaches wherein said acid is carboxylic acid (col. 11, lines 15-40).

Regarding claim 19, Hayase teaches wherein said acid polymer is polyacrylic acid or polystyrene sulfonic acid (col. 11, lines 15-40).

# Allowable Subject Matter

- 3. Claims 12, and 16 are objected to as being dependent upon a rejected base claim, but would be allowable if rewritten in independent form including all of the limitations of the base claim and any intervening claims.
- 4. The following is a statement of reasons for the indication of allowable subject matter:

  Claims 12 and 16 recite, inter alia, wherein said water-soluble film is a polyvinyl alcohol film or
  polyvinyl pyrrolidone film. The art of record does not disclose or anticipate the limitation in
  combination with other claim element nor would it be obvious to modify the art of record so as
  to form a device including the above limitation.
- Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

#### Conclusion

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6. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Quoc Hoang whose telephone number is (571) 272-1780. The examiner can normally be reached on Monday-Friday from 8.00 AM to 5.00 PM.

If attempt to reach the examiner by telephone are unsuccessful, the examiner's supervisor, David Nelms can be reached on (571) 272-1787. The fax phone numbers of the organization where this application or proceeding is assigned are (703) 872-9306 for regular communications and (703) 872-9306 for After Final communications.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is (703) 308-0956.

Quoc Hoang
Patent examiner/AU 2818

Supervisory Patent Examiner Technology Center 2800